

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L4	832	((fluid or gas) near3 (clean\$3 or purg\$3)) with (lens or (project\$3 near optical))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:05
L5	76965	(substrate or wafer) and (mask or reticle) and (lithography or photolithography or (micro near lithography))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:36
L6	132	4 and 5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:36
L7	220919	(radiation or illumination or lamp or light) with (fluid or gas)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:37
L8	220919	(radiation or illumination or lamp or light) with (fluid or gas)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:38
L9	121	8 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:37
L10	6091	(radiation or illumination or lamp or light) with (fluid or gas) with (clean\$3 or purg\$3 or dissociat\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:38
L11	108	10 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/28 13:38

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10/28/05

Interference Search

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	((fluid or gas) near3 (clean\$3 or purg\$3 or dissociat\$3)) and (radiation or illumination or lamp or light) and (nucleat\$3 near (site or surface))).clm.	US-PGPUB	OR	ON	2005/10/28 17:25

7/6
10/28/05